

Attachment (5)

Details of the JPO/IPR Training Course for Practitioners Specializing in Patents

1. Duration:

August 24 – September 11, 2015

[Application Deadline: June 17, 2015]

2. Objectives:

To enhance one's knowledge on intellectual property in general. Also, to deepen one's understanding and enhance one's professional capabilities in terms of operations involving patents, based on hearing lectures and holding discussions on the patent system, preparing specifications and drawings, handling office actions, making amendments, judging patentability, considering patents for innovative technology, using patent information, and handling operations involving licensing.

3. Target Participants (applicants must meet all of the following requirements):

- (1) Target participants should be nominated by the Intellectual Property Office in their countries.
- (2) Target participants should be engaged in the field of IPR.
- (3) Target participants should be university graduates and/or have equivalent professional experience.
- (4) Target participants should be physically and mentally prepared to undergo an intensive training course.
- (5) Target participants should not be students or armed forces personnel.
- (6) Target participants should intend to continue working in the same field after completing the training course.
- (7) Target participants should not have participated in the JPO/IPR training courses during FY 2014, in principle.
- (8) Target participants should have adequate English language competence to attend lectures and discussions, as well as make reports. (Please refer to the Part 6 of the Application Form.)
- (9) Target participants should have considerable knowledge of the IPR system, with more than three years of experience in the field of IPR and have described specifications of patents.
- (10) Target participants should be between 27 and 50 years of age.
- (11) Target participants must be professionals working in one of the following positions:
 - 1) Patent attorneys and IP lawyers; OR
 - 2) Patent practitioners in private businesses.

***Persons working at Japanese enterprises are eligible for this program.**

4. Language:

Lectures, visits and discussions will be carried out in English, or in Japanese with translation into English. Course documents and training materials will be prepared in English.

5. Training Schedule (tentative):

JPO/IPR Training Course for Practitioners Specializing in Patents

	<i>HIDA</i>	<i>APIC</i>
<i>AM</i>	9:30-12:30	10:00-13:00
<i>PM</i>	13:30-16:30	14:00-17:00

<i>Date (Day)</i>	<i>Time</i>	<i>Subject</i>	<i>Location</i>
<i>Aug. 24 (Mon.)</i>	<i>AM</i>	<i>Orientation</i>	<i>HIDA</i>
	<i>PM</i>	<i>Patent Law & Peripheral Law</i>	<i>HIDA</i>
<i>Aug. 25 (Tue.)</i>	<i>All day</i>	<i>Course Overview/Pre-training Report Presentations</i>	<i>HIDA</i>
<i>Aug. 26 (Wed.)</i>	<i>AM</i>	<i>The Current Status and Future Direction of Japanese Industrial Property Administration</i>	<i>APIC</i>
	<i>PM</i>	<i>Visit to the JPO</i>	<i>JPO</i>
<i>Aug. 27 (Thu.)</i>	<i>AM</i>	<i>Invention & Patent Management</i>	<i>APIC</i>
	<i>PM</i>	<i>Valuation of Patent Property Assets</i>	<i>APIC</i>
<i>Aug. 28 (Fri.)</i>	<i>All day</i>	<i>Patent Information Searches & Patent Mapping</i>	<i>APIC</i>
<i>Aug. 29 (Sat.)</i>		<i>Day Off</i>	
<i>Aug. 30 (Sun.)</i>		<i>Day Off</i>	
<i>Aug. 31 (Mon.)</i>	<i>AM</i>	<i>Examination Standards (Novelty)</i>	<i>APIC</i>
	<i>PM</i>	<i>Examination Standards (Exercise)</i>	<i>APIC</i>
<i>Sep. 1 (Tue.)</i>	<i>All day</i>	<i>Patent Information Searches & Patent Mapping</i>	<i>APIC</i>
<i>Sep. 2 (Wed.)</i>	<i>AM</i>	<i>Examination Standards (Inventive Step)</i>	<i>APIC</i>
	<i>PM</i>	<i>Examination Standards (Inventive Step) (Exercise)</i>	<i>APIC</i>
<i>Sep. 3 (Thu.)</i>	<i>All day</i>	<i>Drafting Patent Applications</i>	<i>APIC</i>
<i>Sep. 4 (Fri.)</i>	<i>All day</i>	<i>Current Status of Intellectual Property Rights Management in Private Company</i>	<i>Company</i>
<i>Sep. 5 (Sat.)</i>		<i>Day Off</i>	
<i>Sep. 6 (Sun.)</i>		<i>Day Off</i>	
<i>Sep. 7 (Mon.)</i>	<i>All day</i>	<i>Patent Claim Drafting (Exercise)</i>	<i>APIC</i>

<i>Sep. 8 (Tue.)</i>	<i>AM</i>	<i>Response to Notification of Reasons for Refusal</i>	<i>APIC</i>
	<i>PM</i>	<i>Licensing</i>	<i>APIC</i>
<i>Sep. 9 (Wed.)</i>	<i>All day</i>	<i>Comprehensive Exercise (Novelty, Inventive Step)</i>	<i>APIC</i>
<i>Sep. 10 (Thu.)</i>	<i>All day</i>	<i>Patent Infringement Suits (Case Study)</i>	<i>APIC</i>
<i>Sep. 11 (Fri.)</i>	<i>AM</i>	<i>Overall Discussion</i>	<i>APIC</i>
	<i>PM</i>	<i>Evaluation Meeting / Closing Ceremony</i>	<i>APIC</i>